

A general route to reduce pinhole defects in paint coating on glass substrate

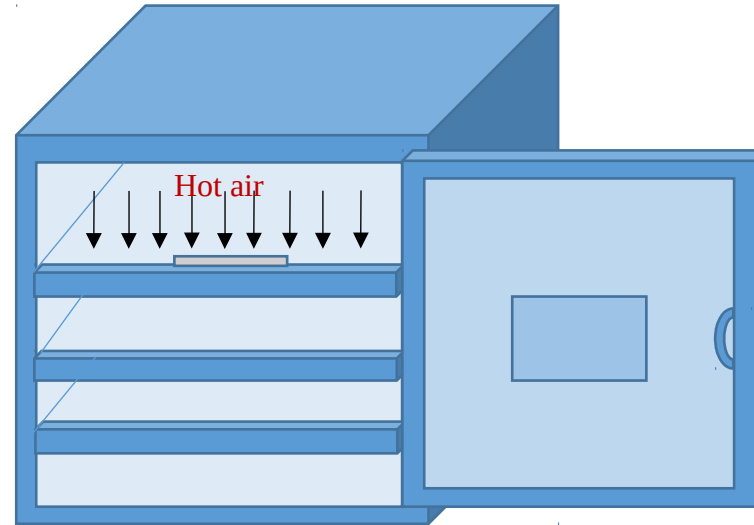
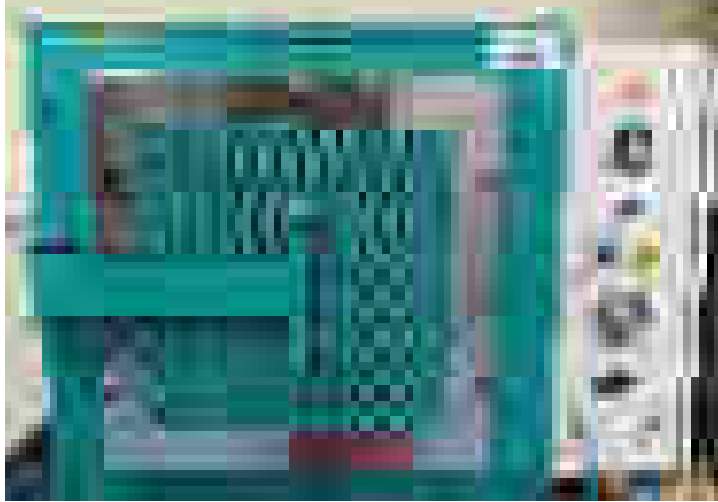
Work Updates

June 2025

Outline

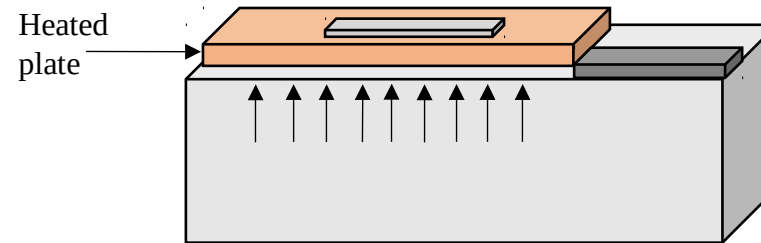
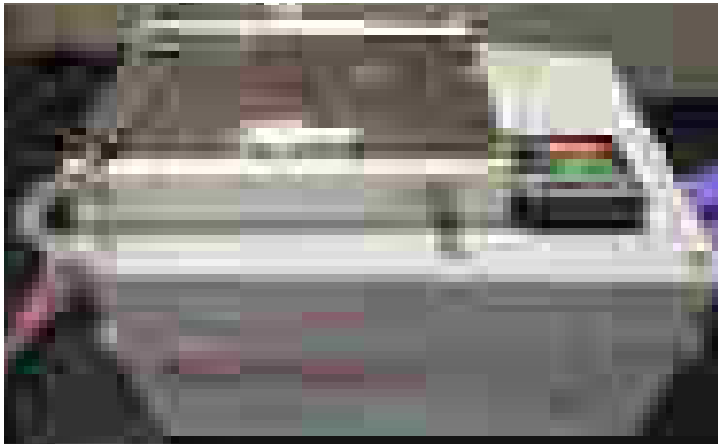
- Introduction
- Method of drying the coating - Top/Bottom heating
- Major parameters affecting the pinhole formation
 - Heating rate
 - Flash-off time
 - Substrate pre-heating temperature
 - Coating speed
 - Thickness
 - Substrate geometry
- Image processing of pinholes
- Conclusion

Top and bottom heating methods



Can control the heating rate

Top heating in hot air oven (RT - 80°C)



Bottom heating on hot plate (RT - 80°C)

Digital videos of bottom heating



Digital videos of bottom heating at 60°C, and 80°C

Calculation of Peclet number

Peclet number is a class of dimensionless numbers relevant in the study of transport phenomena in a continuous medium. It is defined to be the ratio of the rate of advection of a physical quantity by the flow to the rate of diffusion of the same quantity driven by an appropriate gradient.

If $Pe \gg 1$, then the system displays skinning and large discontinuities in volume fraction are expected

If $Pe \ll 1$, diffusion is strong and uniform particle profiles are expected

The particle of radius r with diffusion coefficient D are contained in a film of initial thickness H and the top surface reduces at a evaporative rate E .

Evaporative time $\tau_e = H/E$

Diffusive time $\tau_d = H^2/D$

Peclet number $Pe = \tau_d/\tau_e = HE/D$

Also for colloidal particles the Stokes-Einstein diffusion coefficient,

Where, η - solvent viscosity

k - Boltzmann's constant

T - absolute temperature in Kelvin

Also;

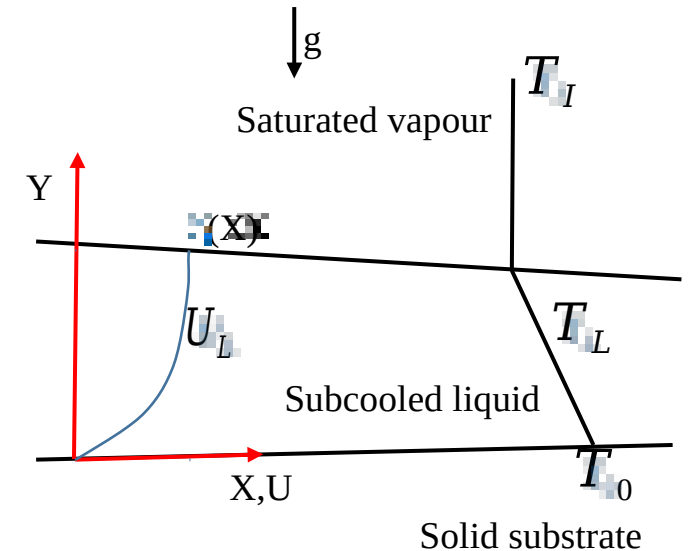
$$Peclet\ number = \frac{6\pi\eta r_0 HE}{kT}$$

Calculation of evaporation velocity

For a horizontal substrate facing upward, the horizontal velocity of evaporation from the horizontal film, as given by GSH Lock (1996), is

where the Jacob number, J , is the ratio of sensible heat to latent heat, the Rayleigh number, Ra , is the ratio of buoyancy to dissipative effects, with the subscript denoting property values of the vapour, L is the length of the film, λ is the latent heat of vaporisation, and ΔT and $\Delta \rho$ are the temperature and density differences between the liquid surface and the ambient, c_p is the specific heat at constant pressure, α is the thermal diffusivity, ν is the kinematic viscosity and ρ is the density. By continuity, the vertical evaporation velocity is then

=



Using the following properties of acetone vapour, $C_{pv}=1263 \text{ Jkg}^{-1}\text{K}^{-1}$, $\nu_v=0.53\times 10^{-6} \text{ Nsm}^{-2}$, $\rho_v=2 \text{ kgm}^{-3}$, $\lambda_v=534\times 10^3 \text{ Jkg}^{-1}$, $\beta=2887 \times 10^{-6}\text{K}^{-1}$, $\Delta T=55\text{K}$, $\alpha_v=0.000124 \text{ m}^2\text{s}^{-1}$ and the mean length of the film $L=70 \text{ nm}$, we obtain

$$Ja = C_{pv}\Delta T/\lambda_v \\ = 0.130$$

$$Ra = g \left(\frac{\Delta\rho}{\rho_v} \right) L^3 / \nu_v \alpha_v$$

$$\text{also, } Ra = g\beta\Delta T L^3 / \nu_v \alpha_v$$

Where β is the coefficient of thermal expansion

$$Ra = 812538$$

$$\text{Evaporative velocity, } V_e = 5.26 \times 10^{-3} \text{ m/s}$$

For a particle radius of 100 nm contained in a film of initial thickness 1mm and an evaporative rate of $V_e=5.26\times 10^{-3} \text{ m/s}$

$$\text{Then the Peclet number, } Pe = 2.15 \times 10^4$$

Parameters affecting the pinhole formation

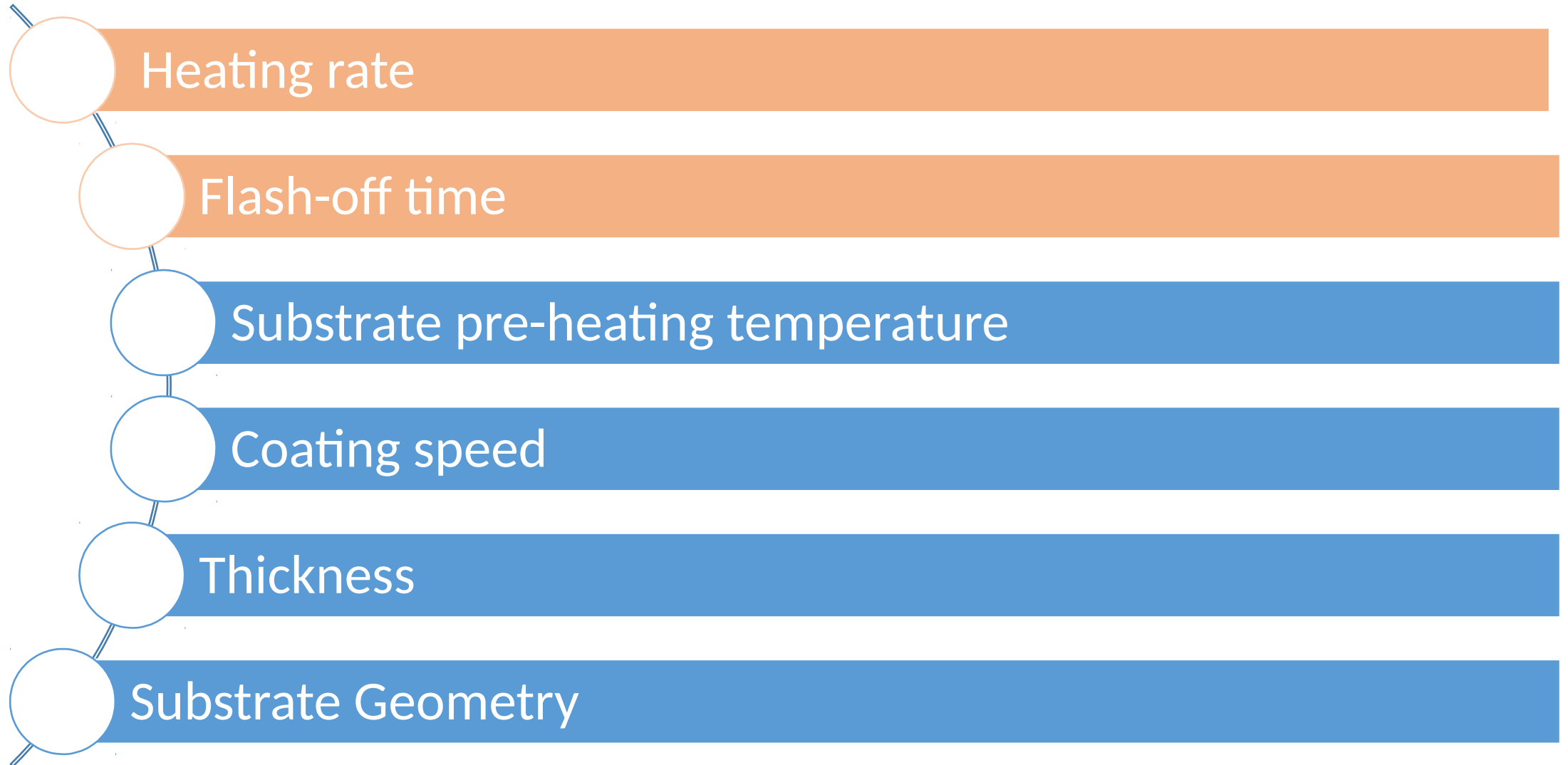


Image processing to study pinhole defects

Front Lighting

Imaging from Bottom

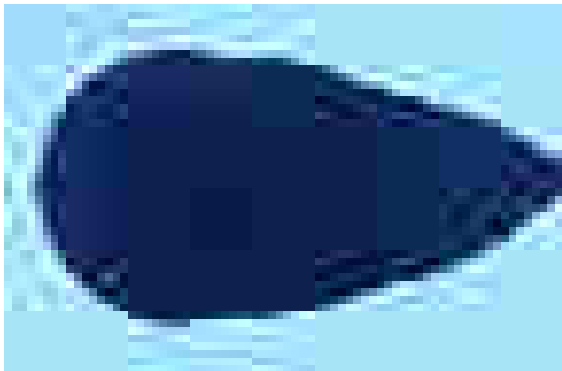
Imaging from Top



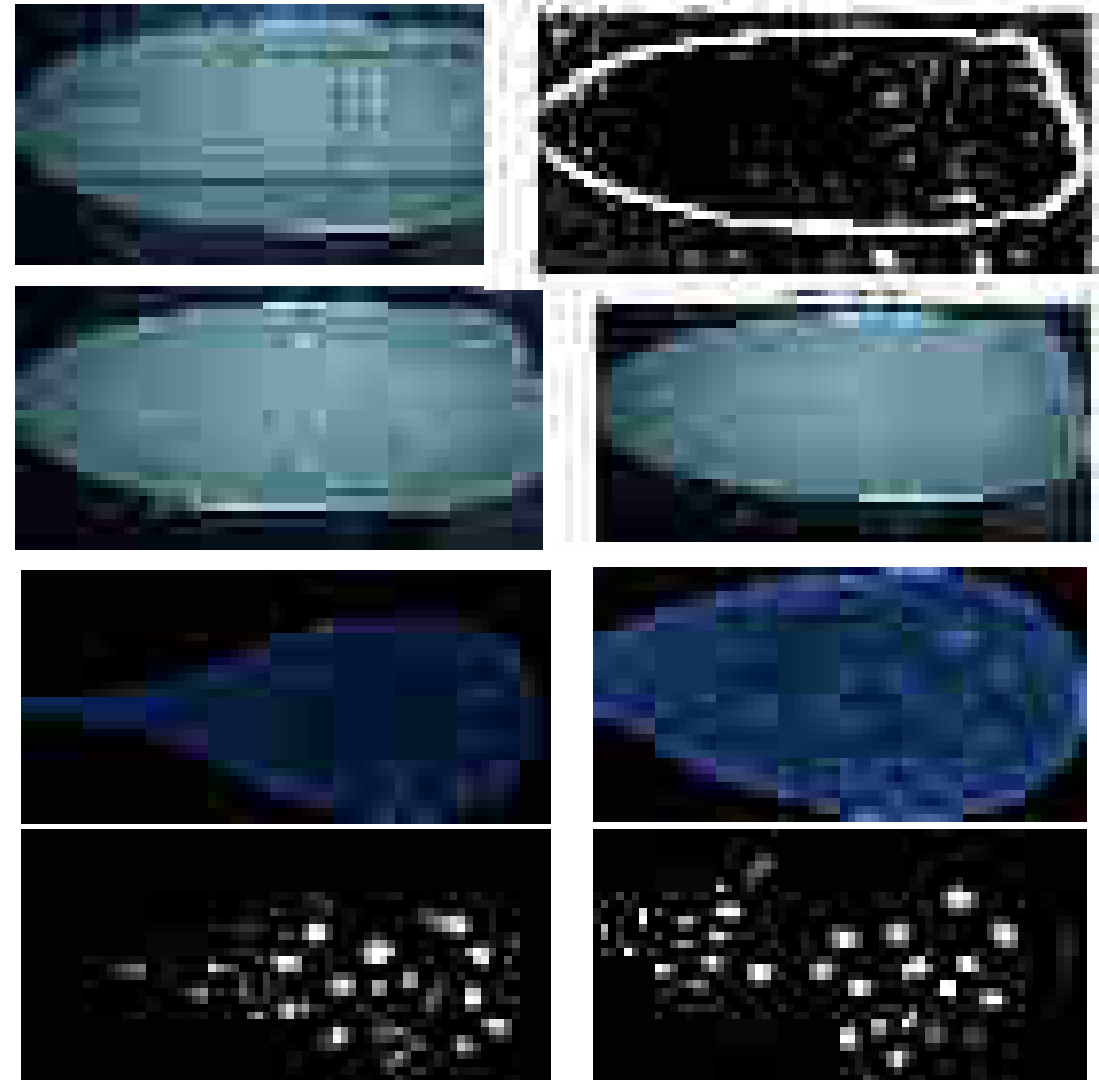
Back Lighting

Imaging from Bottom

Imaging from Top

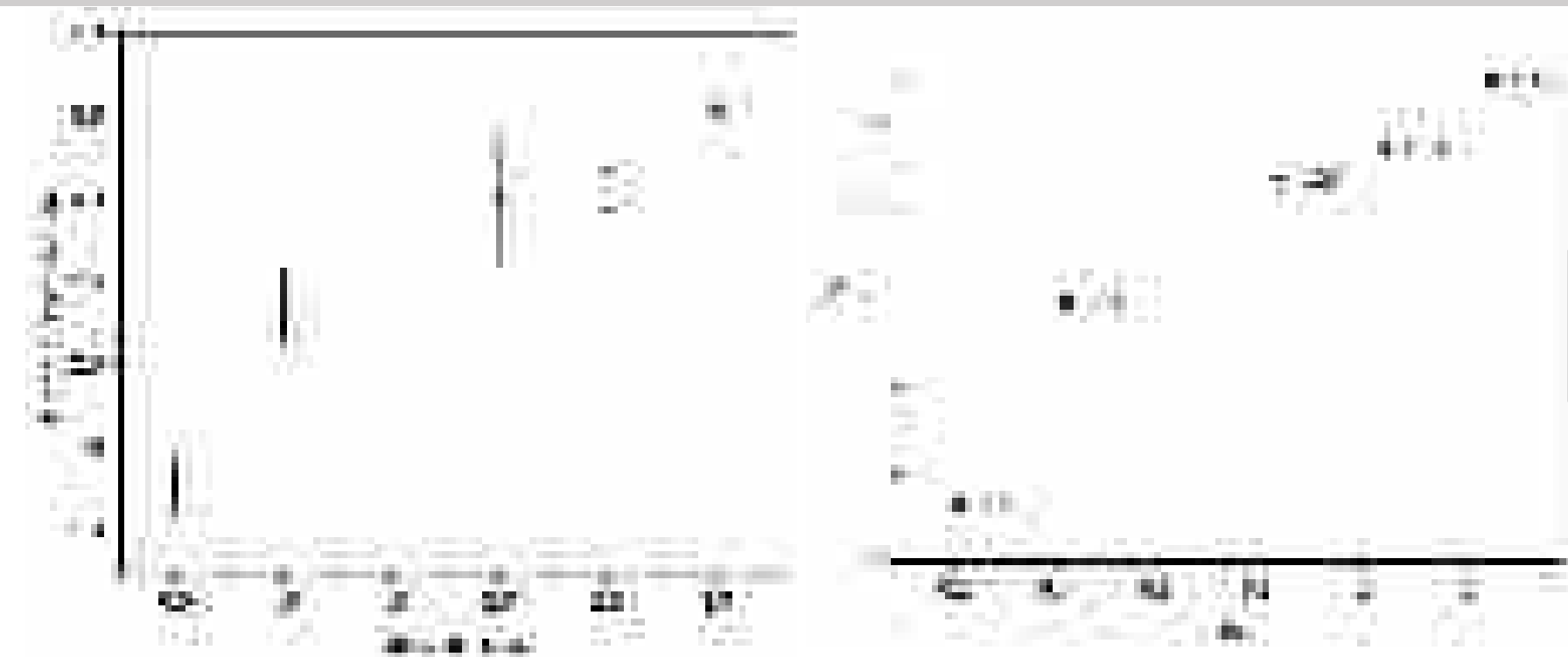


Top-side imaging allows for analysis of open pinholes, while bottom-side imaging enables study of both open and closed pinholes.



Images showing pinhole detection for image processing

Effect of coating thickness on pinhole defects



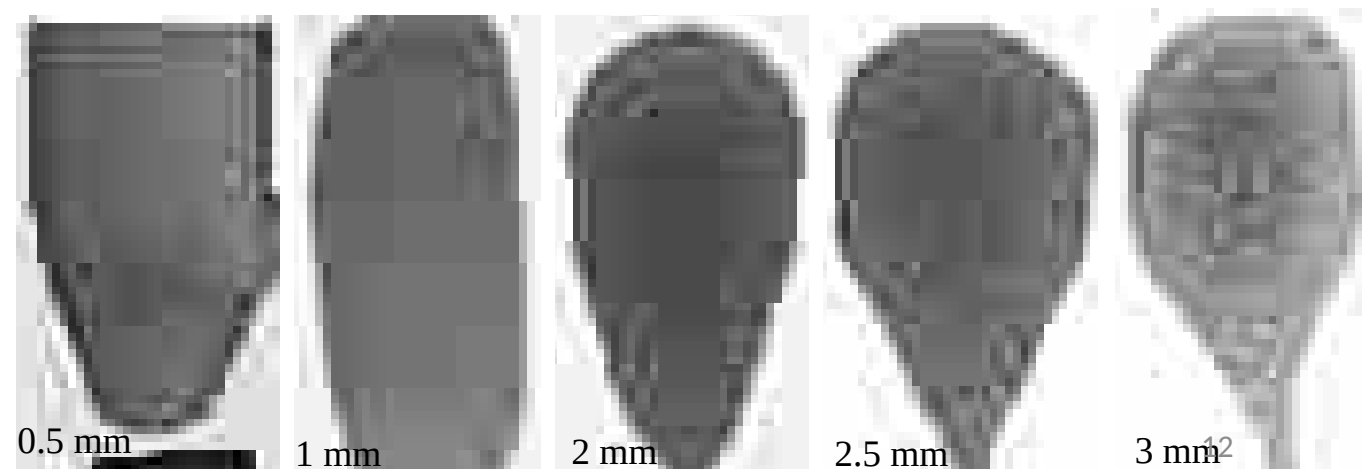
Parameters used

- Coating temperature : Room temperature
- Thickness of coating : Varying (0.5 mm to 3 mm)
- Drying temperature : 40 °C

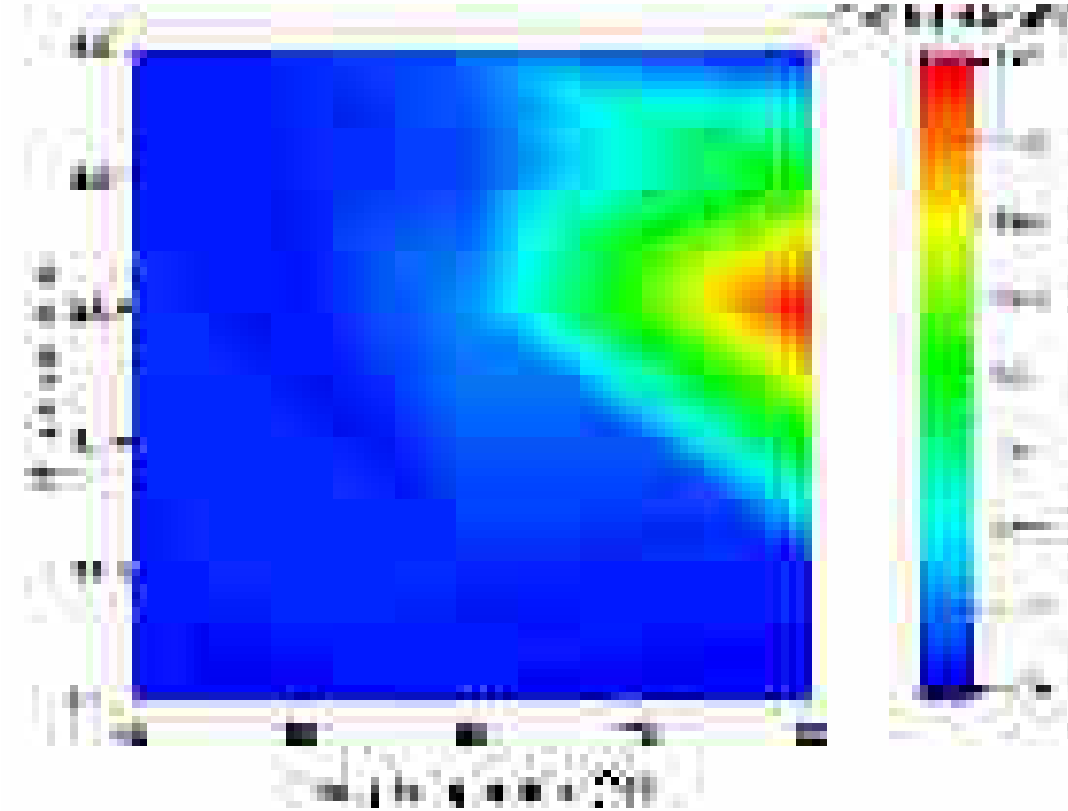
$$V = \frac{1}{2} \pi r^2 L$$

Where V is the volume of the coating, r is the radius of the coating, L is the length of the coating, π is the mathematical constant (3.14159).

Where V is the volume of the coating, r is the radius of the coating, L is the length of the coating.



Area fraction against paint thickness



Coating regime map describing the effects of coating thickness and drying temperature on pinhole area

Effect of substrate-surface geometry and pinhole defects

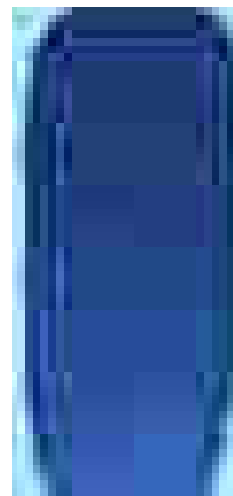


Pinhole defects on painted galvanized steel panel

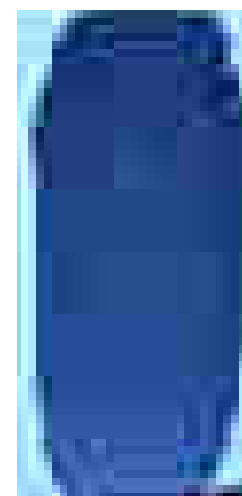
Parameters used

- Coating temperature : Room temperature
- Thickness of coating : 1 mm
- Drying temperature : 40 °C

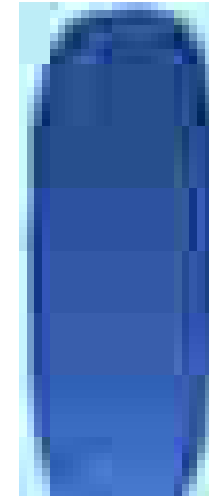
- Micro-geometry of the substrate-surface is important.
- Even an apparently smooth surfaces is inferred with microcavities.



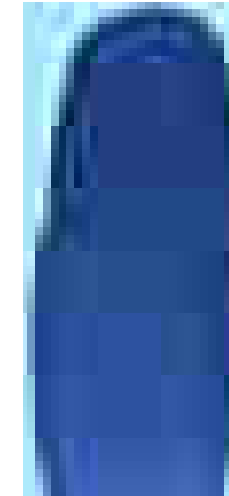
Untreated substrate



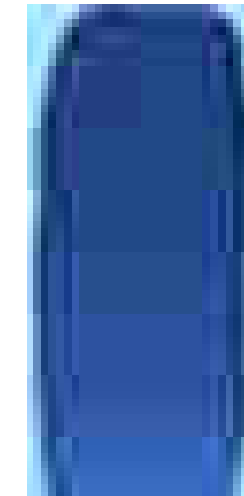
Sonation with acetone



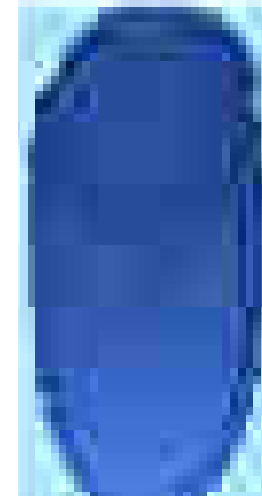
Sonation with DI Water



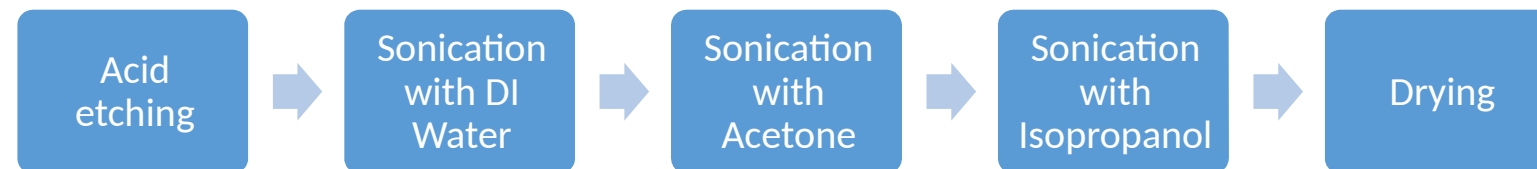
P1500



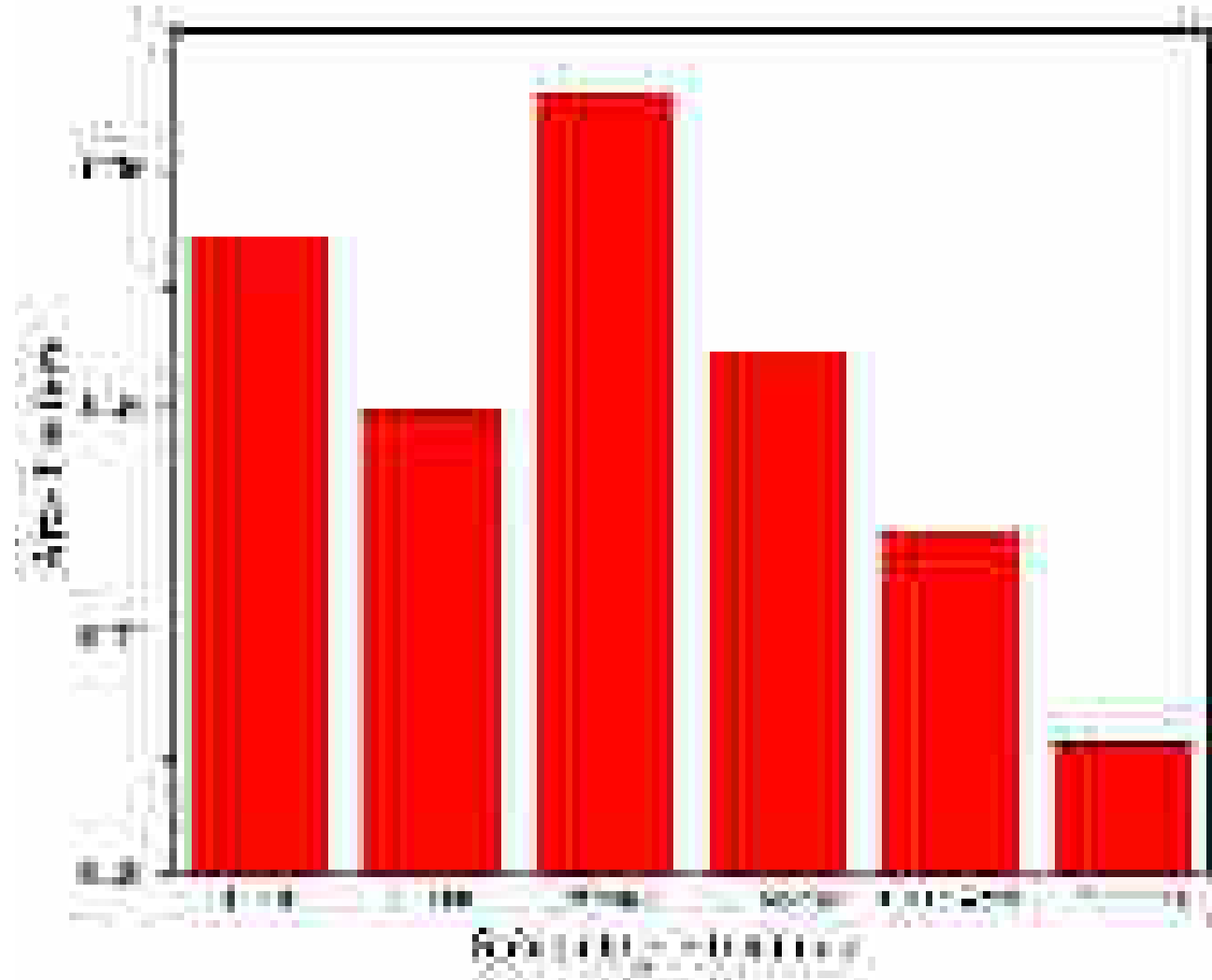
E224



Four step cleaning



Area fraction against substrate geometry



E 224	- Sandpaper grade
P1500	- Sandpaper grade
US acetone	- Ultrasonicated in acetone (10 min)
US DI water	- Ultrasonicated in DI water (10 min)

Conclusions

- **Top heating method** is more effective than bottom heating. **Pe number $\gg 1$** suggests the system displays skinning.
 - Increasing **substrate temperature** leads to higher pinhole defects; solvent boiling occurs at higher substrate temperatures.
- Coating speed does not significantly affect pinholes.
- A combination of higher drying temperatures and higher coating thickness leads to maximum open pinhole area.
- Pinhole radius and area fraction increases with **coating thickness**.
- Heat transfer is by **conduction** rather than convection during paint drying.
- **Substrate geometry** influences pinhole formation.
- **Bubbles do not rise and escape from the glass substrate.** Oh number > 1 and Bo number $\ll 1$ prevents the rising of bubbles from glass substrate.